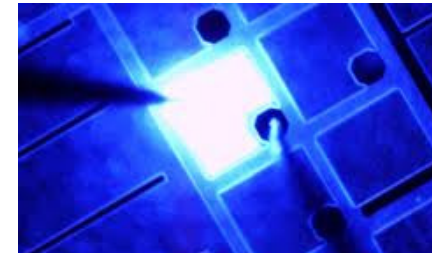


Lecture 9 – 16/04/2025

Light-emitting diodes

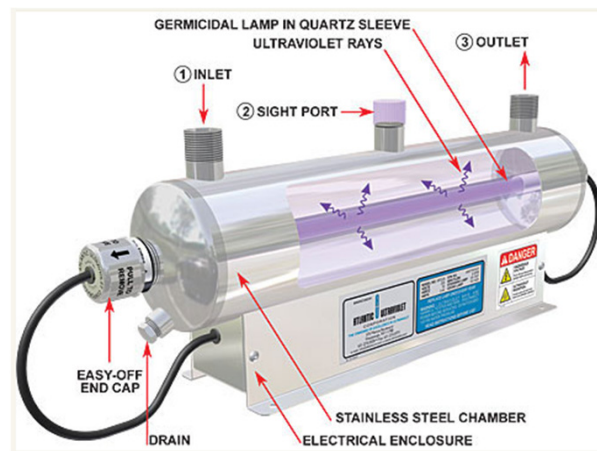
- Basic properties
- Notion of efficiency

Chap. 13 in Rosencher-Vinter \equiv
reference chapter until Lecture 14!

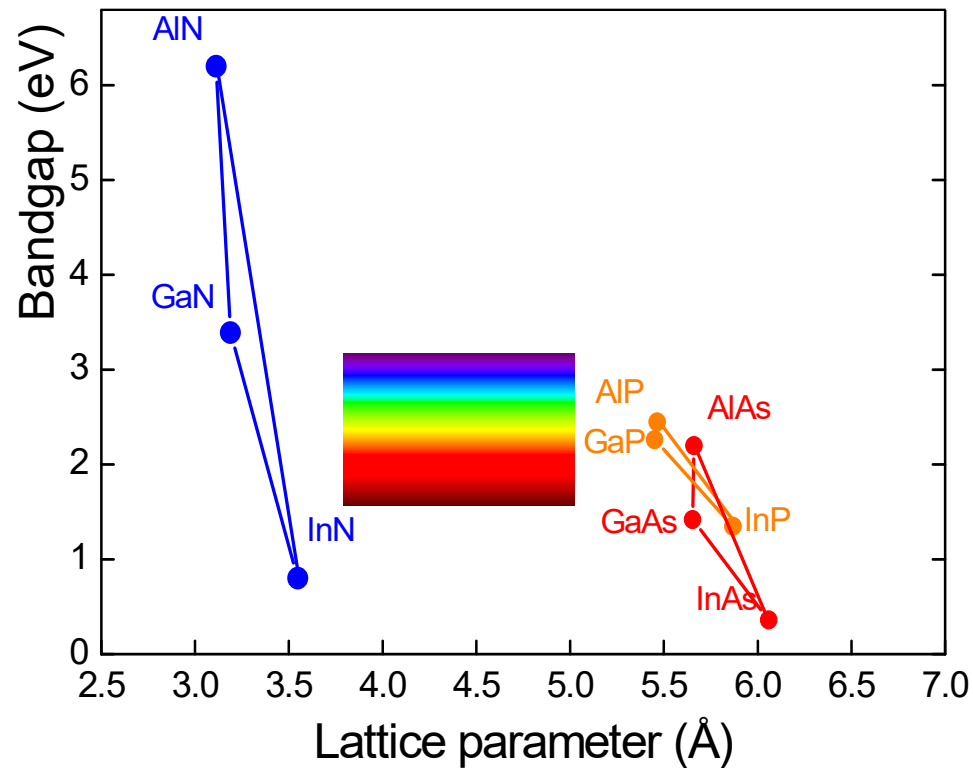


Main applications of light-emitting diodes

- Displays
- Lighting
- Communication
- Purification (UV)
- 3D sensing



Semiconductors for optoelectronics

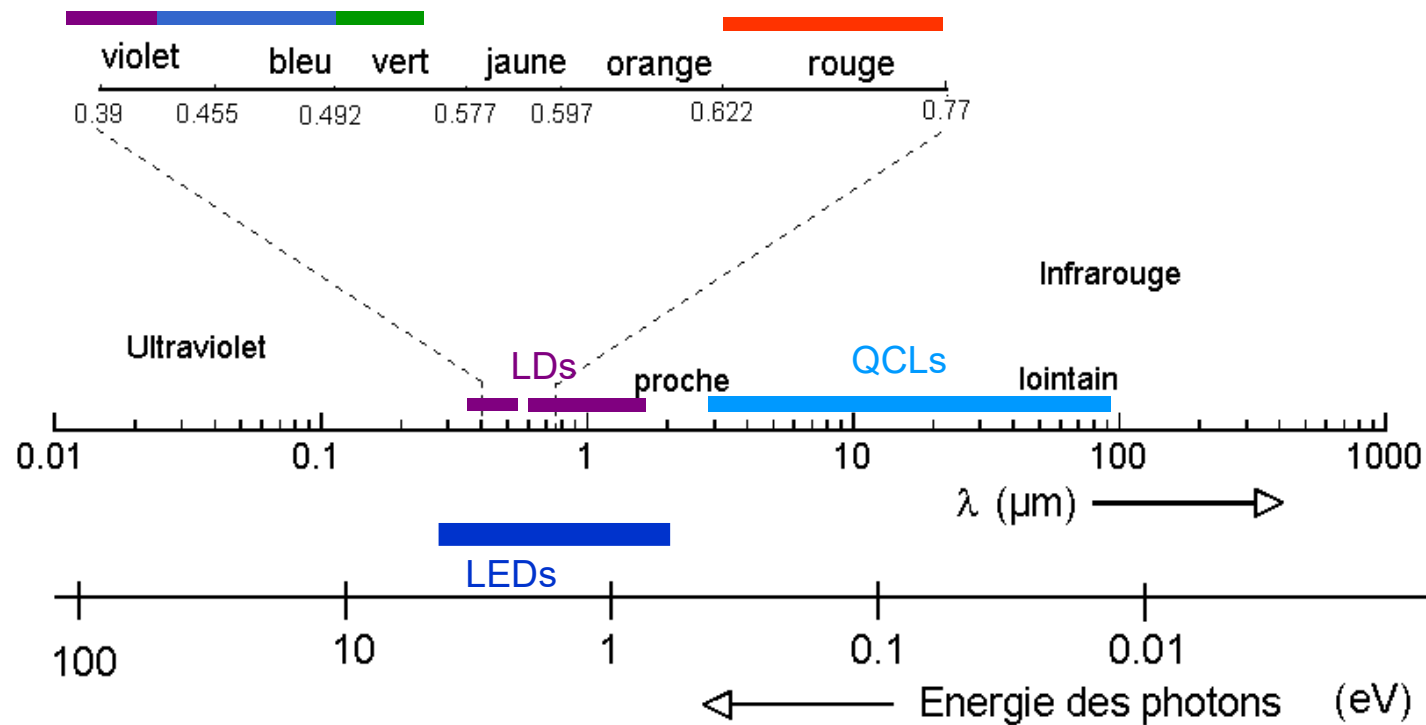


Arsenides: (Al,Ga,In)As

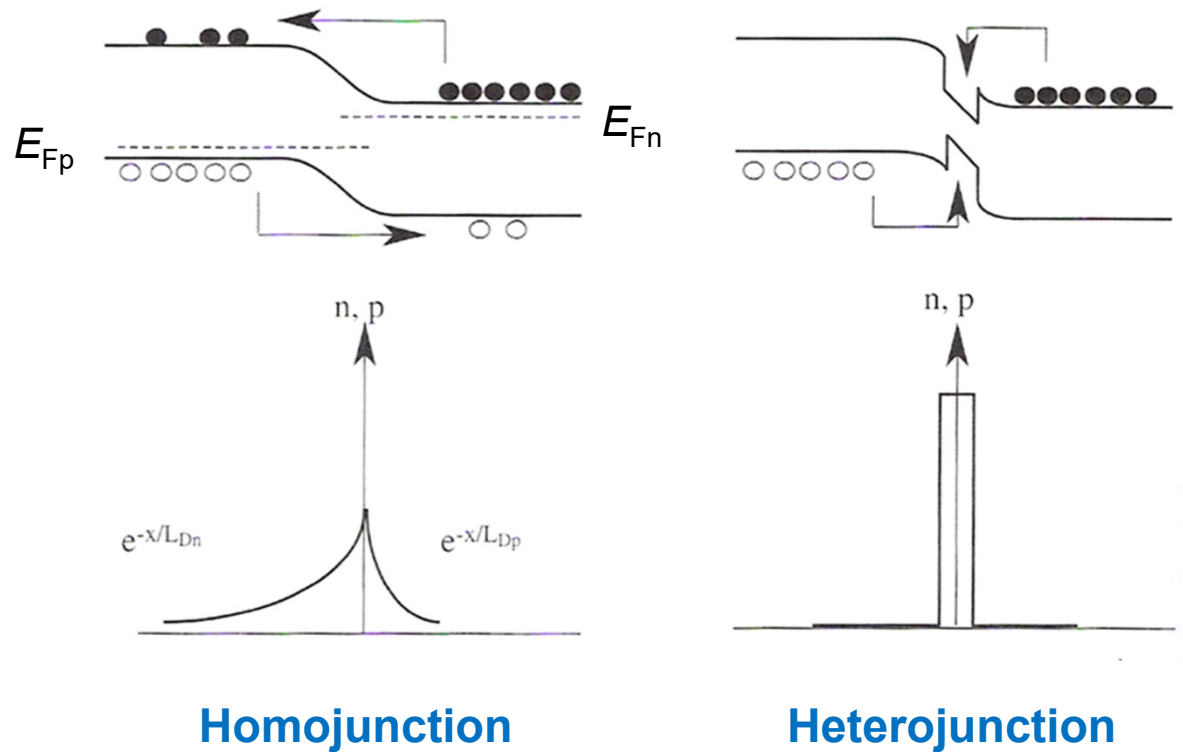
Phosphides: (Al,Ga,In)P

Nitrides: (Al,Ga,In)N

Spectral domain covered by commercial LEDs and LDs



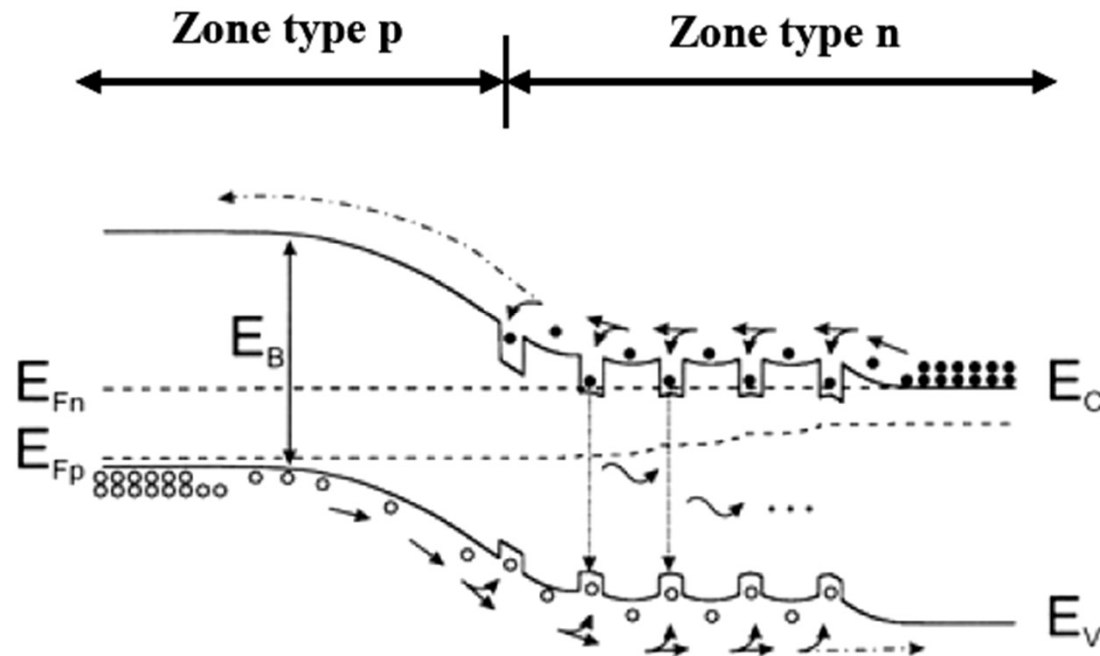
LED structures



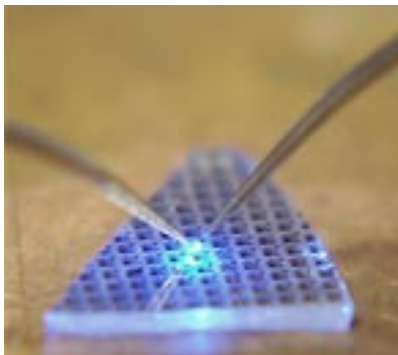
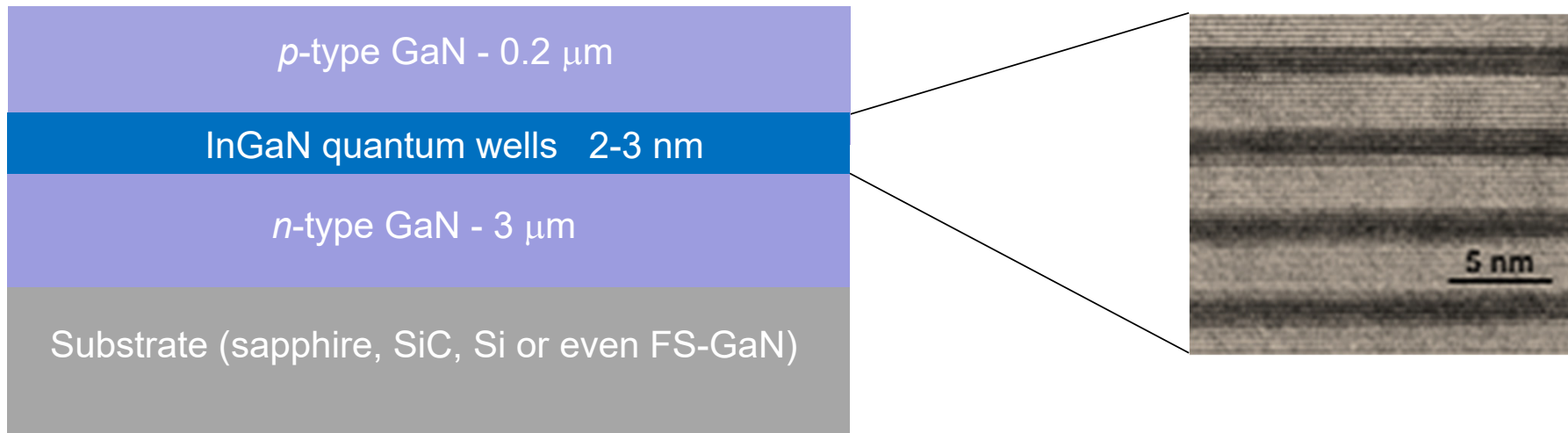
Heterojunction allows for an efficient spatial trapping of injected carriers \Rightarrow increased radiative efficiency, improved operating characteristics ($L-I$ & $I-V$ curves)

LED structures

Multiple quantum well LED



Blue LED structure: a basic picture



Substrate \Rightarrow epilayer material quality

n-type and p-type doped layers \Rightarrow efficient injection

Active region \Rightarrow radiative efficiency

Key markets for III-N LEDs

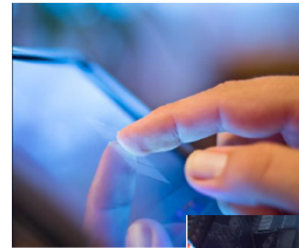
- Automotive

- Forward lighting
- 3D sensing



- Consumer

- Projection
- Tablets/monitors/TV



- Industry

- Video walls
- White goods
- 3D sensing



- General lighting

- Indoor/outdoor lighting
- Shop lighting

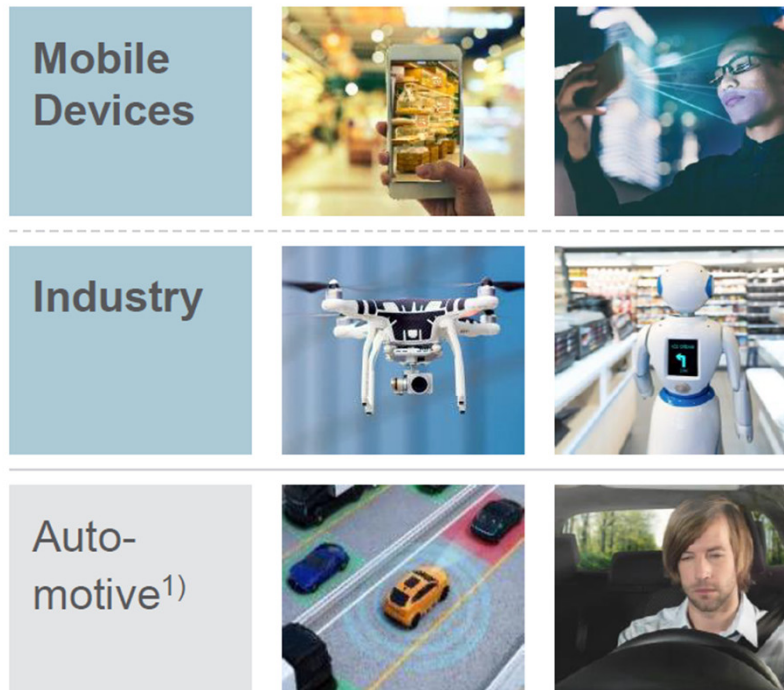


Sources: OSRAM Opto Semiconductors

Emerging LED market: toward 3D sensing

3D Sensing applications

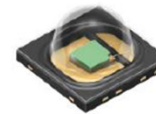
Examples



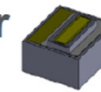
1) Different market that shows same emitter technology

Emitter technologies

LED



Edge emitter



VCSEL²⁾



Not used
for 3D
Sensing



Deep-Dive



2) Vertical-cavity surface-emitting laser

Sources: OSRAM Opto Semiconductors

LED chips: current trends

Evolution of chip sizes

Availability of chip technology at OS

Before 2000

From mid 2000s

Under development

“Standard” LED

Mini LED

μLED



Chip size
(μm)

>200

<200

100 to ~10 (2018)
<10 (2020)
<5 (2022)
<2 for monolithic arrays (2025)


**OS USP
in μLED**

- μLED chips in all colors
- Highest efficiency and reliability
- 6 inch production
- Access to transfer technology
- Proprietary packaging technology

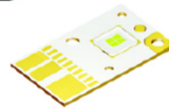
LED market

Projection applications

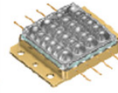
Emitter technologies

 Not used

LED



High power
blue
Laser



RGB low
power
laser



Pixelated
 μ LED
array



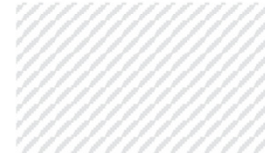
Home Projection



Professional
Projection



Mobile
Projection



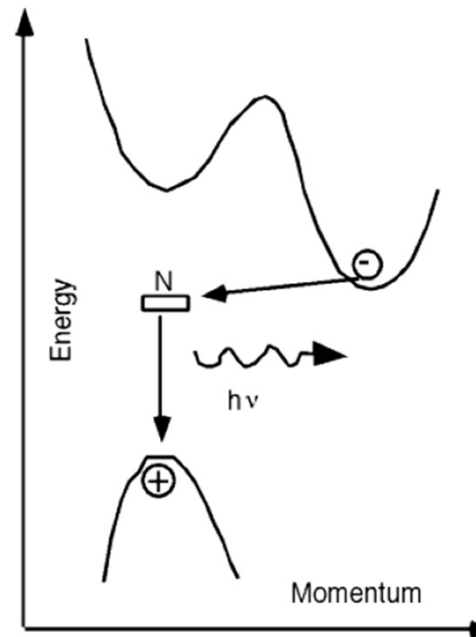
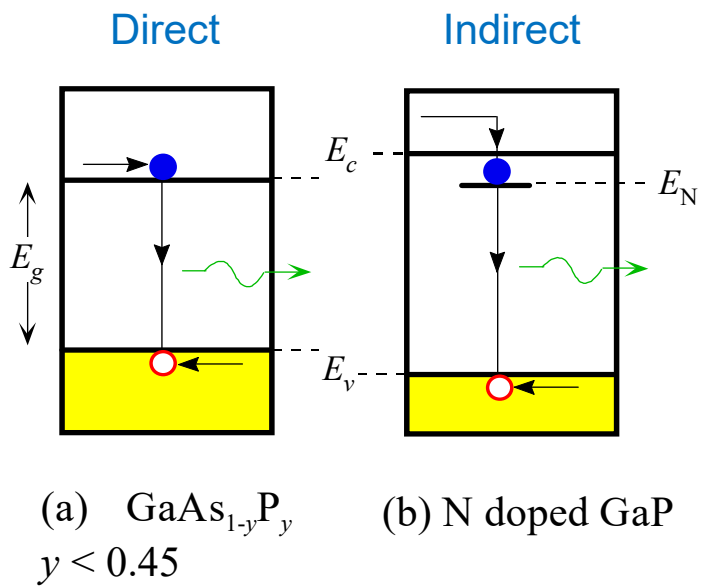
Augmented
Reality



Future scope

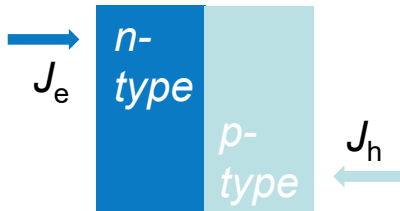
LEDs: basic properties

LEDs made of indirect bandgap semiconductors

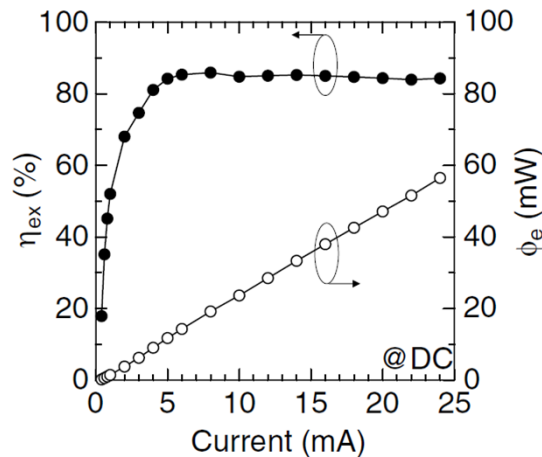


Indirect bandgap \Rightarrow luminescence through a localized defect lying within the bandgap

LEDs: basic properties



Cf. Lectures 7 & 14, fall semester + Chap. 7 Rosencher-Vinter



$$\frac{J_e}{qd} = \frac{J_h}{qd} = \frac{J}{qd} = \frac{n}{\tau_{\text{tot}}} = A_{\text{nr}}n + Bn^2 + C_{\text{Aug}}n^3$$

$$d = V/S \quad \text{Thickness of the active region}$$

$$\frac{1}{\tau_{\text{nr}}} = A_{\text{nr}} + C_{\text{Aug}}n^2$$

$$\frac{1}{\tau_r} = Bn$$

Stimulated emission term neglected

$$\frac{1}{\tau_{\text{tot}}} = \frac{1}{\tau_{\text{nr}}} + \frac{1}{\tau_r}$$

Out of equilibrium carrier density

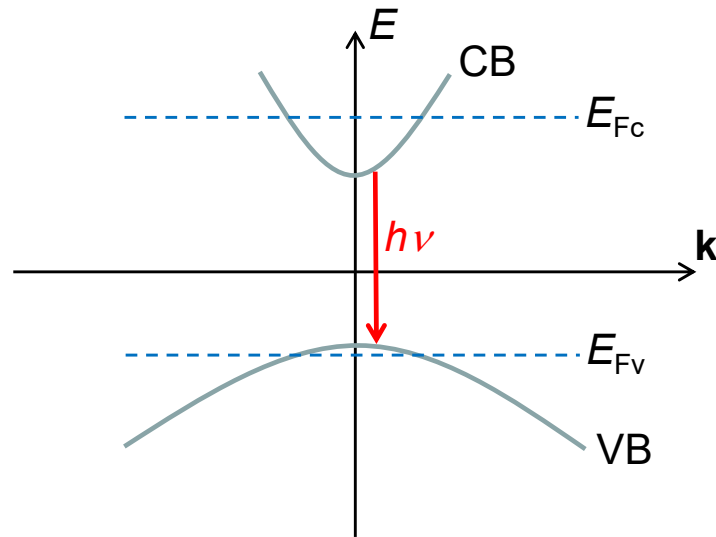
$$n = \frac{J\tau_{\text{tot}}}{qd}$$

⇒ Strong dependence on the thickness of the active region (homo- vs heterojunction (QWs, etc.))

Once n is known, possibility to derive the position of the quasi-Fermi levels E_{Fn} and E_{Fp}

Electrical injection

- Both the valence and the conduction bands get more and more filled upon increasing current injection
- The carrier populations are described by the quasi-Fermi levels E_{Fc} and E_{Fv}



$$f_c(E) = \frac{1}{\exp\left(\frac{E - E_{Fc}}{k_B T}\right) + 1}$$
$$f_v(E) = \frac{1}{\exp\left(\frac{E - E_{Fv}}{k_B T}\right) + 1}$$

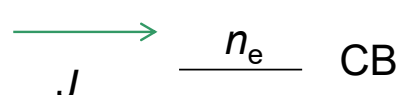
Note that here $f_v(E)$ describes the evolution of the electron population in the valence band!

Electrical injection

Determination of the quasi-Fermi level

$$n = \int_{E_c}^{\infty} \frac{1}{\exp\left(\frac{E - E_{F_c}}{k_B T}\right) + 1} \rho_c(E) dE$$

How many photons are emitted?


 $J_e = J_h = J$ *electrical neutrality*
 and $n_e = n_h = n$ (if the doping levels are not too high)

Steady-state \Rightarrow recombination in the active region

The number of emitted photons is then given by

$$R_{\text{tot}} \times \text{Volume} = J/q \times S \quad \leftarrow \text{Contact size}$$

with R_{tot} the recombination rate (per unit volume)

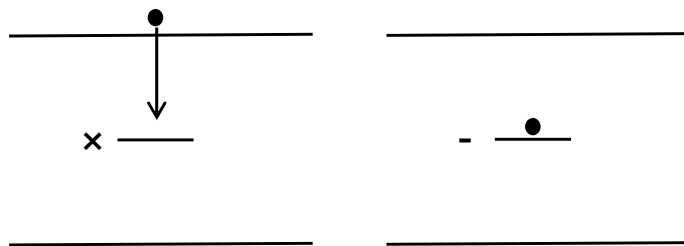
Electrical injection

Different paths for electron-hole recombinations

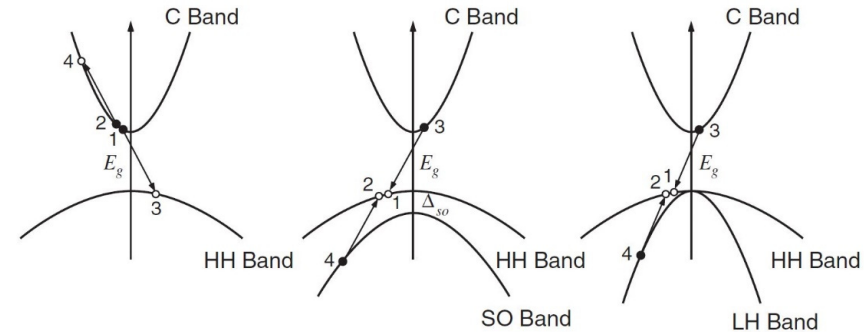
- Non-radiative $A_{nr}n$
- Spontaneous Bn^2
- Auger Cn^3

Cf. Lecture 7, fall semester + Chaps. 5-7
Rosencher-Vinter

B bimol. coeff. $\sim 10^{-12}$ - $10^{-10} \text{ cm}^3\text{s}^{-1}$



**Shockley-Read-Hall
recombinations**



**Auger
recombinations**

Quasi-Fermi levels in bulk semiconductors (reminder)

Example: quasi-Fermi levels in bulk GaAs

Non-degenerate case

$$E_{F_n} = E_C - k_B T \ln \left(\frac{N_C}{n} \right)$$

$$E_{F_p} = E_V + k_B T \ln \left(\frac{N_V}{p} \right)$$

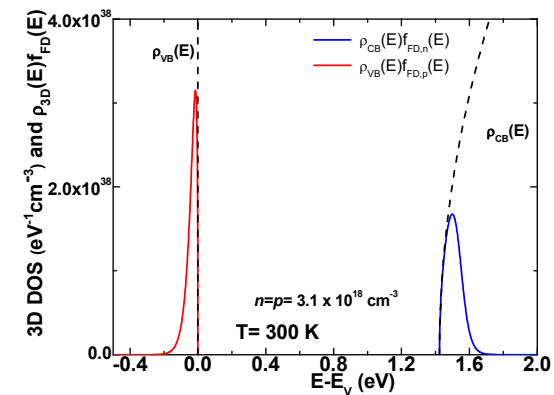
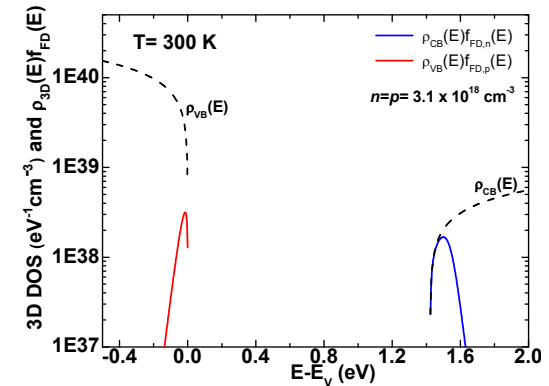
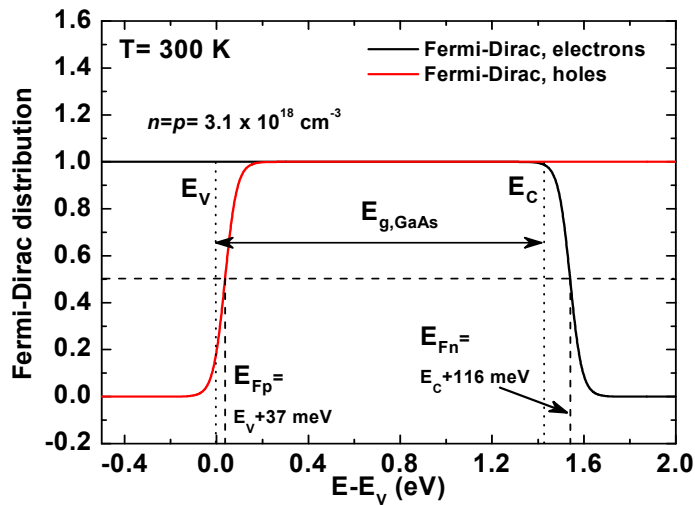
effective DOS

Degenerate case

$$E_{F_n} = E_C + \frac{\hbar^2}{2m_c^*} (3\pi^2 n)^{2/3}$$

$$E_{F_p} = E_V - \frac{\hbar^2}{2m_v^*} (3\pi^2 p)^{2/3}$$

$$N_{c,v} = \frac{1}{4} \left(\frac{2m_{c,v}^* k_B T}{\pi \hbar^2} \right)^{3/2}$$



Spontaneous emission

In an intrinsic bulk semiconductor:

Cf. Lectures 12 & 14, fall semester
+ Chap. 7 Rosencher-Vinter

The spontaneous recombination rate (s^{-1}) between the CB and the VB is given for a state with a wavevector \mathbf{k}

$$r_{\text{sp}}(\mathbf{k}) = A_{\text{cv}} f_{\text{c}}(E_{\text{c}}(\mathbf{k}))(1-f_{\text{v}}(E_{\text{v}}(\mathbf{k})))$$

with $A_{\text{CV}} = 1/\tau_{\text{R}}$ the spontaneous recombination rate

and the radiative lifetime is given by

$$\tau_{\text{R}} = \frac{\pi c^3 \hbar \epsilon_0}{q^2 x_{\text{vc}}^2 n_{\text{op}} \omega_{\text{vc}}^3} = \frac{2\pi c^3 \hbar^2 \epsilon_0 m_0}{q^2 n_{\text{op}} E_{\text{g}} E_{\text{P}}} \quad \tau_{\text{R}} \uparrow \text{ when } E_{\text{g}} \downarrow$$

with x_{vc} the interband dipolar optical matrix element and E_{P} the Kane energy ($\sim 20\text{-}22$ eV)

\Rightarrow It is more challenging to achieve a laser based on a wide bandgap SC!

Spontaneous emission

In an intrinsic bulk semiconductor: Cf. Lecture 14, fall semester + Chap. 7 Rosencher-Vinter

The spectral distribution of spontaneous recombination rate $R_{sp}(h\nu)$ due to a quasi-equilibrium distribution of carriers is then given by

Spin-related \rightarrow

$$R_{sp}(h\nu) = 2 \sum_{\mathbf{k}} r_{sp}(\mathbf{k}) = 2 \sum_{\mathbf{k}} \frac{1}{\tau_R(\mathbf{k})} f_c(\mathbf{k}) (1 - f_v(\mathbf{k})) \delta(E_c - E_v = h\nu)$$

The summation is performed over all \mathbf{k} -vectors verifying the energy conservation condition (hence the Dirac delta)

$$E_c(\mathbf{k}) - E_v(\mathbf{k}) = h\nu = E_g + \frac{\hbar^2 k^2}{2m_r}$$

Expression relying on the verticality of optical transitions in \mathbf{k} -space

which leads to

$$R_{sp}(h\nu) = \int_0^\infty r_{sp}(E) \rho_j(E) \delta(E = h\nu) dE = r_{sp}(h\nu) \rho_j(h\nu)$$

$$\frac{1}{m_r} = \frac{1}{m_c^*} + \frac{1}{m_v^*}$$

$$R_{sp}(h\nu) = \frac{1}{\tau_R} \rho_j(h\nu) f_c(E_c(h\nu)) (1 - f_v(E_v(h\nu)))$$

Joint density of states (JDOS)

LEDs: basic properties

Spectral distribution of spontaneous recombination rate

$$R_{\text{sp}}(h\nu) = \frac{1}{\tau_r} \rho_j(h\nu) f_c(h\nu) (1 - f_v(h\nu)),$$

$$f_c(h\nu) = \frac{1}{1 + \exp\left(\frac{E_c(h\nu) - E_{F_n}}{k_B T}\right)} \cong \exp\left(-\frac{E_c(h\nu) - E_{F_n}}{k_B T}\right),$$

Usually valid for LEDs (non-degenerate case, i.e., Boltzmann approximation is valid)

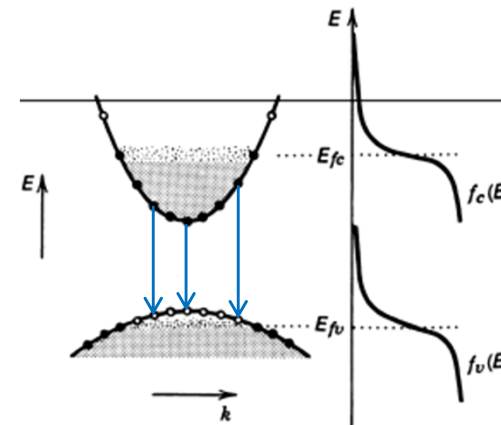
$$E_c(h\nu) = E_g + \frac{m_r}{m_c} (h\nu - E_g),$$

$$f_v(h\nu) = \frac{1}{1 + \exp\left(\frac{E_v(h\nu) - E_{F_p}}{k_B T}\right)},$$

$$E_v(h\nu) = -\frac{m_r}{m_v} (h\nu - E_g),$$

$$\rho_j(h\nu) = \frac{1}{2\pi^2} \left(\frac{2m_r}{\hbar^2}\right)^{3/2} (h\nu - E_g)^{1/2}.$$

Joint density of states (JDOS)

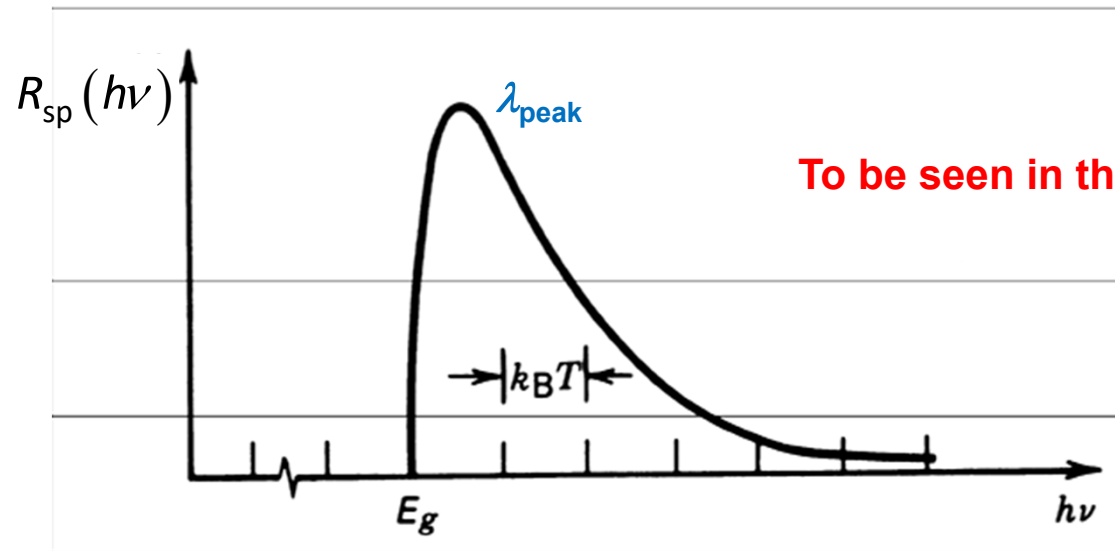


LEDs: basic properties

$$R_{\text{sp}}(h\nu) = K_{\text{sp}} (h\nu - E_g)^{1/2} \exp\left(-\frac{h\nu - E_g}{k_B T}\right),$$

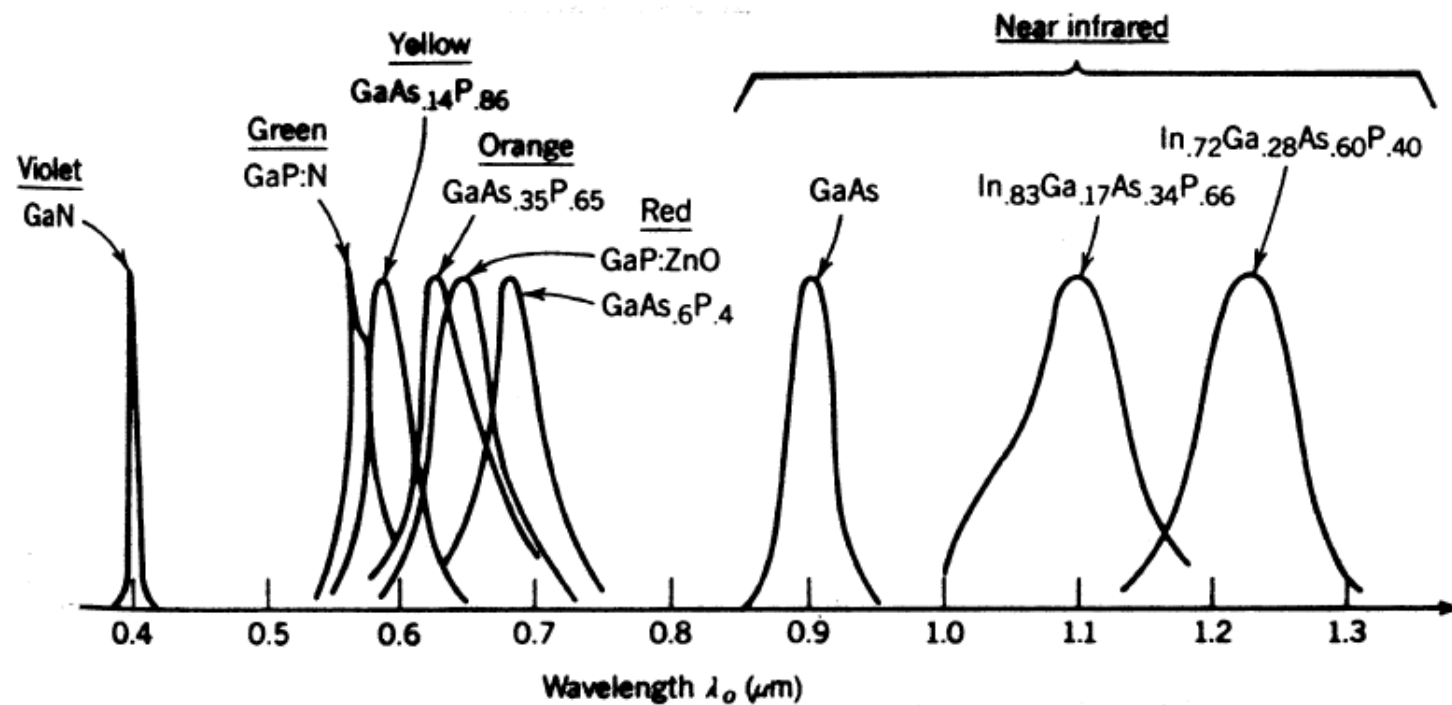
$$\text{with } K_{\text{sp}} = \frac{(2m_r)^{3/2}}{\pi \hbar^2 \tau_r} \exp\left(\frac{\Delta E_F - E_g}{k_B T}\right) = \frac{(2m_r)^{3/2}}{\pi \hbar^2 \tau_r} \underbrace{e^{\frac{eV_{\text{app}} - E_g}{k_B T}}}_{\propto J}.$$

$E_{F_C} - E_{F_V}$



LEDs emission spectra

Spectral density emitted by LEDs



$$\Delta\lambda \propto \lambda_{\text{peak}}^2 k_B T$$

LED efficiency

Internal quantum efficiency (IQE, η_i):

$\eta_i = [\text{generated photons}]/[\text{injected electrons}]$ with $[\] \equiv$ particle number

$$\eta_i = \frac{\tau_{\text{tot}}}{\tau_r} = \frac{\tau_{\text{nr}}}{\tau_{\text{nr}} + \tau_r} = \frac{Bn}{A_{\text{nr}} + Bn + Cn^2}$$

with τ_{nr} non-radiative lifetime
 τ_r radiative lifetime

The internal quantum efficiency can be as high as 99% at 300 K for InGaN QWs!

The photon flux is $\Phi = \eta_{\text{inj}} \eta_i J/q$

Injection efficiency \equiv capture of carriers by the active region (QWs)

with J the electron current density

LED efficiency

External quantum efficiency (EQE, η): [emitted photons]/[electrons]

$$\eta = \eta_{\text{inj}} \eta_{\text{i}} \eta_{\text{ext}} \longrightarrow \text{extraction efficiency}$$

